

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|------------------------------------------------------------------------------------------------------------------|-------------------------------------------------------|------------------|---------|------------------|
| L1 | 39 | (insulating dielectric) adj (film layer) and (borazine borazene) | US-PGPUB; USPAT; USOCR | OR | ON | 2005/08/22 12:27 |
| L2 | 6 | L1 and (insulating dielectric) adj (film layer) with electrode | US-PGPUB; USPAT; USOCR | OR | ON | 2005/08/22 12:27 |
| L3 | 36 | L1 and device | US-PGPUB; USPAT; USOCR | OR | ON | 2005/08/22 12:27 |
| L4 | 7 | L1 and ((insulating dielectric) adj (film layer) and (borazene borazine)).clm. | US-PGPUB; USPAT; USOCR | OR | ON | 2005/08/22 12:28 |
| L5 | 6 | L1 and ((insulating dielectric) adj (film layer) and (borazene borazine) and device).clm. | US-PGPUB; USPAT; USOCR | OR | ON | 2005/08/22 12:28 |
| L6 | 23 | (insulating dielectric) adj (film layer) and (borazine borazene) | EPO; JPO; DERWENT ; IBM_TDB | OR | ON | 2005/08/22 12:28 |
| L7 | 10 | (sei near2 tsunoda hideharu near2 nobutoki noboru near2 mikami).in. and dielectric and (boron borazene borazine) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2005/08/22 12:28 |